L· Number	Hits	Search Text	DB	Time stamp
3	238	((((((((((((silicon (amorphous near3 silicon) a-silicon a-si)) and (air ambient atmosphere)) and ((native natural) near5 oxid$6)) and laser) and (anneal$3 heat$3)) and crystal$10) and (HF (hydrogen near3 fluoride) (hydrofluor$3 near3 acid))) and (hydrogen "H.sub.2")) (((((((((silicon (amorphous near3 silicon) a-silicon a-si)) and (air ambient atmosphere)) and ((native natural) near5 oxid$6)) and laser) and (anneal$3 heat$3)) and crystal$10) and (HF (hydrogen near3 fluoride) (hydrofluor$3 near3 acid))) and (oxygen "O.sub.2")) (((((((((silicon (amorphous near3 silicon) a-silicon a-si)) and (air ambient atmosphere)) and ((native natural) near5 oxid$6)) and laser) and (anneal$3 heat$3)) and crystal$10) and (HF (hydrogen near3 fluoride) (hydrofluor$3 near3 acid))) and (nitrogen "N.sub.2"))) and (TFT (thin near3 film near3 transistor))	USPAT; US-PGPUB	2004/06/16 17:33
5	53	((laser same ((natural near3 oxide) native))) and (TFT (thin near3 film near3 transistor))	USPAT; US-PGPUB	2004/06/16 13:26
4	885	(laser same ((natural near3 oxide) native))	USPAT; US-PGPUB	2004/06/16 17:11
6	126	(laser same ((natural near3 oxide) native))	EPO; JPO; DERWENT; IBM_TDB	2004/06/16 17:11
7	183	(laser and ((natural near3 oxide) native))	EPO; JPO; DERWENT; IBM_TDB	2004/06/16 17:11
8	183	((laser and ((natural near3 oxide) native))) ((laser same ((natural near3 oxide) native)))	EPO; JPO; DERWENT; IBM_TDB	2004/06/16 17:12
9	9	(((laser and ((natural near3 oxide) native))) ((laser same ((natural near3 oxide) native)))) and (TFT (thin near3 film near3 transistor))	EPO; JPO; DERWENT; IBM_TDB	2004/06/16 17:12
10	0	((((((((((((silicon (amorphous near3 silicon) a-silicon a-si)) and (air ambient atmosphere)) and ((native natural) near5 oxid$6)) and laser) and (anneal$3 heat$3)) and crystal$10) and (HF (hydrogen near3 fluoride) (hydrofluor$3 near3 acid))) and (hydrogen "H.sub.2")) (((((((((silicon (amorphous near3 silicon) a-silicon a-si)) and (air ambient atmosphere)) and ((native natural) near5 oxid$6)) and laser) and (anneal$3 heat$3)) and crystal$10) and (HF (hydrogen near3 fluoride) (hydrofluor$3 near3 acid))) and (oxygen "O.sub.2")) (((((((((silicon (amorphous near3 silicon) a-silicon a-si)) and (air ambient atmosphere)) and ((native natural) near5 oxid$6)) and laser) and (anneal$3 heat$3)) and crystal$10) and (HF (hydrogen near3 fluoride) (hydrofluor$3 near3 acid))) and (nitrogen "N.sub.2"))) and (TFT (thin near3 film near3 transistor))	EPO; JPO; DERWENT; IBM_TDB	2004/06/16 17:33
-	425153	(silicon (amorphous near3 silicon) a-silicon a-si)	USPAT; US-PGPUB	2004/06/03 21:33
-	219940	((silicon (amorphous near3 silicon) a-silicon a-si)) and (air ambient atmosphere)	USPAT; US-PGPUB	2004/06/03 21:35
-	6996	(((silicon (amorphous near3 silicon) a-silicon a-si)) and (air ambient atmosphere)) and ((native natural) near5 oxid$6)	USPAT; US-PGPUB	2004/06/03 21:35

-	1886	((((silicon (amorphous near3 silicon) a-silicon a-si)) and (air ambient atmosphere)) and ((native natural) near5 oxid$6)) and laser	USPAT; US-PGPUB	2004/06/03 21:35
-	1751	(((((silicon (amorphous near3 silicon) a-silicon a-si)) and (air ambient atmosphere)) and ((native natural) near5 oxid$6)) and laser) and (anneal$3 heat$3)	USPAT; US-PGPUB	2004/06/03 21:19
-	1393	((((((silicon (amorphous near3 silicon) a-silicon a-si)) and (air ambient atmosphere)) and ((native natural) near5 oxid$6)) and laser) and (anneal$3 heat$3)) and crystal$10	USPAT; US-PGPUB	2004/06/03 21:35
-	572	(((((((silicon (amorphous near3 silicon) a-silicon a-si)) and (air ambient atmosphere)) and ((native natural) near5 oxid$6)) and laser) and (anneal$3 heat$3)) and crystal$10) and (HF (hydrogen near3 fluoride))	USPAT; US-PGPUB	2004/06/03 21:35
-	787	((((((((silicon (amorphous near3 silicon) a-silicon a-si)) and (air ambient atmosphere)) and ((native natural) near5 oxid$6)) and laser) and (anneal$3 heat$3)) and crystal$10) and (HF (hydrogen near3 fluoride) (hydrofluor$3 near3 acid))	USPAT; US-PGPUB	2004/06/03 21:25
-	620	(((((((((silicon (amorphous near3 silicon) a-silicon a-si)) and (air ambient atmosphere)) and ((native natural) near5 oxid$6)) and laser) and (anneal$3 heat$3)) and crystal$10) and (HF (hydrogen near3 fluoride) (hydrofluor$3 near3 acid))) and (hydrogen "H.sub.2")	USPAT; US-PGPUB	2004/06/03 21:36
-	706	(((((((((silicon (amorphous near3 silicon) a-silicon a-si)) and (air ambient atmosphere)) and ((native natural) near5 oxid$6)) and laser) and (anneal$3 heat$3)) and crystal$10) and (HF (hydrogen near3 fluoride) (hydrofluor$3 near3 acid))) and (oxygen "O.sub.2")	USPAT; US-PGPUB	2004/06/03 21:36
-	598	(((((((((silicon (amorphous near3 silicon) a-silicon a-si)) and (air ambient atmosphere)) and ((native natural) near5 oxid$6)) and laser) and (anneal$3 heat$3)) and crystal$10) and (HF (hydrogen near3 fluoride) (hydrofluor$3 near3 acid))) and (nitrogen "N.sub.2")	USPAT; US-PGPUB	2004/06/03 21:36
-	768	((((((((((silicon (amorphous near3 silicon) a-silicon a-si)) and (air ambient atmosphere)) and ((native natural) near5 oxid$6)) and laser) and (anneal$3 heat$3)) and crystal$10) and (HF (hydrogen near3 fluoride) (hydrofluor$3 near3 acid))) and (hydrogen "H.sub.2")) (((((((((silicon (amorphous near3 silicon) a-silicon a-si)) and (air ambient atmosphere)) and ((native natural) near5 oxid$6)) and laser) and (anneal$3 heat$3)) and crystal$10) and (HF (hydrogen near3 fluoride) (hydrofluor$3 near3 acid))) and (oxygen "O.sub.2")) (((((((((silicon (amorphous near3 silicon) a-silicon a-si)) and (air ambient atmosphere)) and ((native natural) near5 oxid$6)) and laser) and (anneal$3 heat$3)) and crystal$10) and (HF (hydrogen near3 fluoride) (hydrofluor$3 near3 acid))) and (nitrogen "N.sub.2"))	USPAT; US-PGPUB	2004/06/03 21:27

-	235	`(((((((((silicon (amorphous near3 silicon) a-silicon a-si)) and (air ambient atmosphere)) and ((native natural) near5 oxid$6)) and laser) and (anneal$3 heat$3)) and crystal$10) and (HF (hydrogen near3 fluoride) (hydrofluor$3 near3 acid))) and (hydrogen "H.sub.2")) (((((((((silicon (amorphous near3 silicon) a-silicon a-si)) and (air ambient atmosphere)) and ((native natural) near5 oxid$6)) and laser) and (anneal$3 heat$3)) and crystal$10) and (HF (hydrogen near3 fluoride) (hydrofluor$3 near3 acid))) and (oxygen "O.sub.2")) (((((((((silicon (amorphous near3 silicon) a-silicon a-si)) and (air ambient atmosphere)) and ((native natural) near5 oxid$6)) and laser) and (anneal$3 heat$3)) and crystal$10) and (HF (hydrogen near3 fluoride) (hydrofluor$3 near3 acid))) and (nitrogen "N.sub.2"))) and (TFT (thin near3 film near3 transistor))`	USPAT; US-PGPUB	2004/06/16 13:14
-	425229	`(silicon (amorphous near3 silicon) a-silicon a-si alpha-silicon alpha-Si)`	USPAT; US-PGPUB	2004/06/03 21:34
-	219971	`((silicon (amorphous near3 silicon) a-silicon a-si alpha-silicon alpha-Si) ) and (air ambient atmosphere)`	USPAT; US-PGPUB	2004/06/03 21:35
-	6996	`(((silicon (amorphous near3 silicon) a-silicon a-si alpha-silicon alpha-Si) ) and (air ambient atmosphere)) and ((native natural) near5 oxid$6)`	USPAT; US-PGPUB	2004/06/03 21:35
-	1886	`((((silicon (amorphous near3 silicon) a-silicon a-si alpha-silicon alpha-Si) ) and (air ambient atmosphere)) and ((native natural) near5 oxid$6)) and laser`	USPAT; US-PGPUB	2004/06/03 21:35
-	1460	`(((((silicon (amorphous near3 silicon) a-silicon a-si alpha-silicon alpha-Si) ) and (air ambient atmosphere)) and ((native natural) near5 oxid$6)) and laser) and crystal$10`	USPAT; US-PGPUB	2004/06/03 21:35
-	587	`((((((silicon (amorphous near3 silicon) a-silicon a-si alpha-silicon alpha-Si) ) and (air ambient atmosphere)) and ((native natural) near5 oxid$6)) and laser) and crystal$10) and (HF (hydrogen near3 fluoride))`	USPAT; US-PGPUB	2004/06/03 21:36
-	446	`(((((((silicon (amorphous near3 silicon) a-silicon a-si alpha-silicon alpha-Si) ) and (air ambient atmosphere)) and ((native natural) near5 oxid$6)) and laser) and crystal$10) and (HF (hydrogen near3 fluoride))) and (hydrogen "H.sub.2")`	USPAT; US-PGPUB	2004/06/03 21:36
-	524	`(((((((silicon (amorphous near3 silicon) a-silicon a-si alpha-silicon alpha-Si) ) and (air ambient atmosphere)) and ((native natural) near5 oxid$6)) and laser) and crystal$10) and (HF (hydrogen near3 fluoride))) and (oxygen "O.sub.2")`	USPAT; US-PGPUB	2004/06/03 21:36
-	381	`((((((((silicon (amorphous near3 silicon) a-silicon a-si alpha-silicon alpha-Si) ) and (air ambient atmosphere)) and ((native natural) near5 oxid$6)) and laser) and crystal$10) and (HF (hydrogen near3 fluoride))) and (oxygen "O.sub.2")) and (nitrogen "N.sub.2")`	USPAT; US-PGPUB	2004/06/03 21:37

| | | 564 | (((((((((silicon (amorphous near3 silicon) a-silicon a-si alpha-silicon alpha-Si)) and (air ambient atmosphere)) and ((native natural) near5 oxid$6)) and laser) and crystal$10) and (HF (hydrogen near3 fluoride))) and (hydrogen "H.sub.2")) (((((((((silicon (amorphous near3 silicon) a-silicon a-si alpha-silicon alpha-Si)) and (air ambient atmosphere)) and ((native natural) near5 oxid$6)) and laser) and crystal$10) and (HF (hydrogen near3 fluoride))) and (oxygen "O.sub.2")) ((((((((((silicon (amorphous near3 silicon) a-silicon a-si alpha-silicon alpha-Si)) and (air ambient atmosphere)) and ((native natural) near5 oxid$6)) and laser) and crystal$10) and (HF (hydrogen near3 fluoride))) and (oxygen "O.sub.2")) and (nitrogen "N.sub.2")) | USPAT; US-PGPUB | 2004/06/03 21:37 |
| - | | 780 | ((((((((((silicon (amorphous near3 silicon) a-silicon a-si)) and (air ambient atmosphere)) and ((native natural) near5 oxid$6)) and laser) and (anneal$3 heat$3)) and crystal$10) and (HF (hydrogen near3 fluoride) (hydrofluor$3 near3 acid))) and (hydrogen "H.sub.2")) (((((((((silicon (amorphous near3 silicon) a-silicon a-si)) and (air ambient atmosphere)) and ((native natural) near5 oxid$6)) and laser) and (anneal$3 heat$3)) and crystal$10) and (HF (hydrogen near3 fluoride) (hydrofluor$3 near3 acid))) and (oxygen "O.sub.2")) ((((((((((silicon (amorphous near3 silicon) a-silicon a-si)) and (air ambient atmosphere)) and ((native natural) near5 oxid$6)) and laser) and (anneal$3 heat$3)) and crystal$10) and (HF (hydrogen near3 fluoride) (hydrofluor$3 near3 acid))) and (nitrogen "N.sub.2"))) (((((((((silicon (amorphous near3 silicon) a-silicon a-si alpha-silicon alpha-Si)) and (air ambient atmosphere)) and ((native natural) near5 oxid$6)) and laser) and crystal$10) and (HF (hydrogen near3 fluoride))) and (hydrogen "H.sub.2")) (((((((((silicon (amorphous near3 silicon) a-silicon a-si alpha-silicon alpha-Si)) and (air ambient atmosphere)) and ((native natural) near5 oxid$6)) and laser) and crystal$10) and (HF (hydrogen near3 fluoride))) and (oxygen "O.sub.2")) ((((((((((silicon (amorphous near3 silicon) a-silicon a-si alpha-silicon alpha-Si)) and (air ambient atmosphere)) and ((native natural) near5 oxid$6)) and laser) and crystal$10) and (HF (hydrogen near3 fluoride))) and (oxygen "O.sub.2")) and (nitrogen "N.sub.2"))) | USPAT; US-PGPUB | 2004/06/03 21:38 |

| | | 235 | ((((((((((((silicon (amorphous near3 silicon) a-silicon a-si)) and (air ambient atmosphere)) and ((native natural) near5 oxid$6)) and laser) and (anneal$3 heat$3)) and crystal$10) and (HF (hydrogen near3 fluoride) (hydrofluor$3 near3 acid))) and (hydrogen "H.sub.2")) (((((((silicon (amorphous near3 silicon) a-silicon a-si)) and (air ambient atmosphere)) and ((native natural) near5 oxid$6)) and laser) and (anneal$3 heat$3)) and crystal$10) and (HF (hydrogen near3 fluoride) (hydrofluor$3 near3 acid))) and (oxygen "O.sub.2")) (((((((silicon (amorphous near3 silicon) a-silicon a-si)) and (air ambient atmosphere)) and ((native natural) near5 oxid$6)) and laser) and (anneal$3 heat$3)) and crystal$10) and (HF (hydrogen near3 fluoride) (hydrofluor$3 near3 acid))) and (nitrogen "N.sub.2"))) (((((((silicon (amorphous near3 silicon) a-silicon a-si alpha-silicon alpha-Si)) and (air ambient atmosphere)) and ((native natural) near5 oxid$6)) and laser) and crystal$10) and (HF (hydrogen near3 fluoride))) and (hydrogen "H.sub.2")) (((((((silicon (amorphous near3 silicon) a-silicon a-si alpha-silicon alpha-Si)) and (air ambient atmosphere)) and ((native natural) near5 oxid$6)) and laser) and crystal$10) and (HF (hydrogen near3 fluoride))) and (oxygen "O.sub.2")) (((((((silicon (amorphous near3 silicon) a-silicon a-si alpha-silicon alpha-Si)) and (air ambient atmosphere)) and ((native natural) near5 oxid$6)) and laser) and crystal$10) and (HF (hydrogen near3 fluoride))) and (oxygen "O.sub.2")) and (nitrogen "N.sub.2"))))) and (TFT (thin near3 film near3 transistor)) | USPAT; US-PGPUB | 2004/06/03 21:38 |